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demchenko@franko.lviv.ua**Key indicators**Single-crystal X-ray study  
 $T = 295$  K  
Mean  $\sigma(\text{Ni}-\text{Si}) = 0.001$  Å  
 $R$  factor = 0.025  
 $wR$  factor = 0.057  
Data-to-parameter ratio = 15.6For details of how these key indicators were automatically derived from the article, see <http://journals.iucr.org/e>.**Erbium nickel disilicide, ErNiSi<sub>2</sub>**

Single crystals of ErNiSi<sub>2</sub> were synthesized from the corresponding elements by arc melting. The ternary intermetallic compound crystallizes in the orthorhombic space group *Cmcm* and adopts the CeNiSi<sub>2</sub> structure type [Bodak & Gladyshevskii (1969). *Kristallografiya*, **14**, 990–994], with all four crystallographically unique atoms in special positions of site symmetry *m2m*.

**Comment**

Ternary intermetallics of rare earth metals with the general formula *RETX*<sub>2</sub> (where *RE* is a rare earth metal, *T* is a transition metal and *X* is a *p*-block element) crystallize mostly in 23 structure types (Parthé *et al.*, 1993–1994), *viz.* monoclinic NdRuSi<sub>2</sub>, CeCoC<sub>2</sub> and LaCuS<sub>2</sub>, orthorhombic CeNiSi<sub>2</sub>, YIrGe<sub>2</sub>, LuMnGe<sub>2</sub>, ZrCrSi<sub>2</sub>, CeRhGe<sub>2</sub>, TbFeSi<sub>2</sub>, LaTmIr<sub>2</sub>Ge<sub>4</sub>, LuNiSn<sub>2</sub>, NdAgAs<sub>2</sub>, MgCuAl<sub>2</sub>, NdNiGa<sub>2</sub>, CeRhSn<sub>2</sub> (Niepmann *et al.*, 1999), ScRhSi<sub>2</sub>, ScFeSi<sub>2</sub>, CeNiC<sub>2</sub>, ScCoC<sub>2</sub> and LuRuB<sub>2</sub>, and tetragonal HfCuSi<sub>2</sub>, ScCoC<sub>2</sub> and LaRhC<sub>2</sub>.

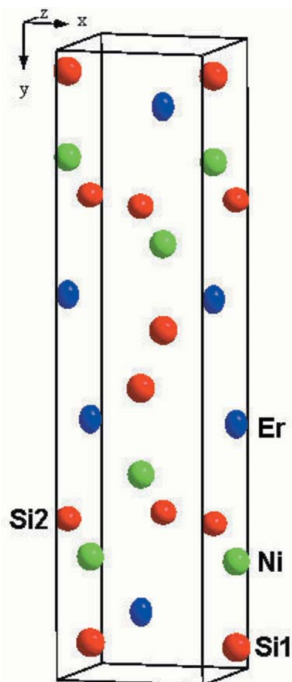
The *RETX*<sub>2</sub> phases have been the focus of special attention due to their interesting magnetic and electrical properties, *e.g.* the Kondo effect. An accurate determination of the crystal structure for phases of this composition is a basic requirement for the better understanding of their physical properties. The existence of the phase ErNiSi<sub>2</sub> was first reported by Bodak & Gladyshevskii (1969) who, on the basis of X-ray powder diffraction data, established that the crystal structure adopts the orthorhombic CeNiSi<sub>2</sub> structure type. Analogous results were obtained by Gil *et al.* (1994). In these investigations, information about structural data (atomic coordinates, displacement parameters) was not presented. Thus, it seemed appropriate to determine completely the crystal structure of ErNiSi<sub>2</sub>, and we present these results here.

ErNiSi<sub>2</sub> adopts the CeNiSi<sub>2</sub> structure type (Bodak & Gladyshevskii, 1969). A clinographic projection of the unit-cell contents is shown in Fig. 1. The coordination around Er (site symmetry *m2m*) consists of 21 atoms, if bonding interactions are considered for distances < 4.0 Å, resulting in an [ErSi<sub>4</sub>Ni<sub>4</sub>Si<sub>6</sub>NiEr<sub>6</sub>] polyhedron (Fig. 2*a*). The coordination polyhedron around the Ni atom (site symmetry *m2m*) is a monocapped tetragonal antiprism, [NiSi<sub>5</sub>Er<sub>4</sub>], made up of 4 Er atoms in one basal plane with a capping Si atom, and 4 Si atoms in the second basal plane, if bonding interactions are considered for distances < 3.1 Å (Fig. 2*b*). The coordination polyhedron around atom Si1 (site symmetry *m2m*, bonding interactions < 3.1 Å) is a tricapped trigonal prism, [Si1Ni<sub>2</sub>Si<sub>2</sub>Er<sub>6</sub>], with one additional Ni and two Er atoms as capping atoms (Fig. 2*c*). The coordination polyhedron around atom Si2 (site symmetry *m2m*, bonding interactions < 3.1 Å) is a distorted cuboctahedron, [Si2Ni<sub>4</sub>Si<sub>4</sub>Er<sub>4</sub>] (Fig. 2*d*).

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**Figure 1**  
A clinographic projection of the  $\text{ErNiSi}_2$  unit-cell contents, with displacement ellipsoids drawn at the 95% probability level.

The interatomic distances (Table 1) are in good agreement with the sums of the atomic radii (Emsley, 1991). The shortest distance with the highest deviation (93% of the sum of the atomic radii) is observed between Ni and Si atoms, with an Ni—Si distance of 2.255 (3) Å.

## Experimental

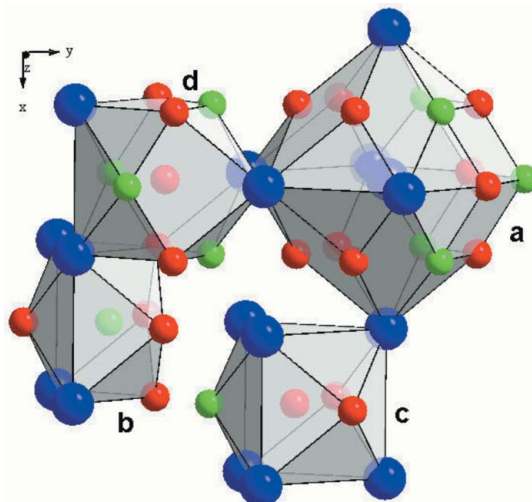
The single crystal used in this work was extracted from an alloy with nominal composition  $\text{Er}_{23}\text{Ni}_{27}\text{Si}_{50}$ , which was prepared by arc melting of the initial components (purity better than 99.9%) in an electric arc furnace with a water-cooled copper bottom (Ti-getter) under an argon atmosphere, and annealed at 870 K. A preliminary crystallographic investigation was performed using Laue and rotation methods (RKV-86 and RGNS-2 chambers, Mo  $K\alpha$  radiation).

### Crystal data

$\text{ErNiSi}_2$	Mo $K\alpha$ radiation
$M_r = 282.15$	Cell parameters from 1017 reflections
Orthorhombic, $Cmcm$	$\theta = 4.9\text{--}32.7^\circ$
$a = 3.9423$ (9) Å	$\mu = 40.49 \text{ mm}^{-1}$
$b = 16.502$ (3) Å	$T = 295$ (2) K
$c = 3.9319$ (9) Å	Plate, metallic light grey
$V = 255.79$ (9) Å <sup>3</sup>	$0.21 \times 0.19 \times 0.04 \text{ mm}$
$Z = 4$	
$D_x = 7.327 \text{ Mg m}^{-3}$	

### Data collection

Oxford Diffraction Xcalibur3 CCD area-detector diffractometer	281 independent reflections
$\omega$ scans	280 reflections with $I > 2\sigma(I)$
Absorption correction: analytical <i>CrysAlis RED</i> (Oxford Diffraction, 2005)	$R_{\text{int}} = 0.039$
$T_{\text{min}} = 0.002$ , $T_{\text{max}} = 0.199$	$\theta_{\text{max}} = 32.7^\circ$
1025 measured reflections	$h = -5 \rightarrow 4$
	$k = -24 \rightarrow 23$
	$l = -5 \rightarrow 5$



**Figure 2**  
The coordination polyhedra around (a) the Er atom, (b) the Ni atom, and (c) and (d) the Si atoms. Er atoms are blue, Ni atoms green and Si atoms red.

### Refinement

Refinement on $F^2$	$(\Delta/\sigma)_{\text{max}} < 0.001$
$R[F^2 > 2\sigma(F^2)] = 0.025$	$\Delta\rho_{\text{max}} = 4.29 \text{ e \AA}^{-3}$
$wR(F^2) = 0.057$	$\Delta\rho_{\text{min}} = -2.85 \text{ e \AA}^{-3}$
$S = 1.33$	Extinction correction: <i>SHELXL97</i> (Sheldrick, 1997)
281 reflections	Extinction coefficient: 0.0048 (7)
18 parameters	
$w = 1/[\sigma^2(F_o^2) + (0.023P)^2 + 5.5174P]$	
where $P = (F_o^2 + 2F_c^2)/3$	

**Table 1**

Selected interatomic distances (Å).

Er—Si1 <sup>i</sup>	2.9899 (10)	Ni—Si1	2.255 (3)
Er—Ni <sup>ii</sup>	3.0178 (6)	Ni—Si2 <sup>vii</sup>	2.3110 (15)
Er—Si2 <sup>iii</sup>	3.090 (2)	Ni—Si2 <sup>iv</sup>	2.3202 (15)
Er—Si1 <sup>iv</sup>	3.100 (2)	Si1—Si1 <sup>viii</sup>	2.358 (3)
Er—Er <sup>v</sup>	3.9319 (9)	Si2—Si2 <sup>ix</sup>	2.7840 (5)
Er—Er <sup>vi</sup>	3.9423 (9)		

Symmetry codes: (i)  $-x - \frac{1}{2}, -y + \frac{1}{2}, -z$ ; (ii)  $-x + \frac{1}{2}, -y + \frac{1}{2}, -z + 1$ ; (iii)  $x + \frac{1}{2}, y - \frac{1}{2}, z$ ; (iv)  $x - \frac{1}{2}, y - \frac{1}{2}, z$ ; (v)  $x, y, z - 1$ ; (vi)  $x - 1, y, z$ ; (vii)  $-x, -y + 1, -z$ ; (viii)  $-x, -y + 1, -z + 1$ ; (ix)  $-x + \frac{1}{2}, -y + \frac{3}{2}, -z + 1$ .

Atomic coordinates were standardized using the *STRUCTURE-TIDY* program (Gelato & Parthé, 1987). The highest maximum residual electron density is 1.06 Å from atom Si1 and the deepest hole is 0.65 Å from the Er atom.

Data collection: *CrysAlis CCD* (Oxford Diffraction, 2004); cell refinement: *CrysAlis CCD*; data reduction: *CrysAlis RED* (Oxford Diffraction, 2005); program(s) used to solve structure: *SHELXS97* (Sheldrick, 1997); program(s) used to refine structure: *SHELXL97* (Sheldrick, 1997); molecular graphics: *DIAMOND* (Brandenburg, 1999); software used to prepare material for publication: *SHELXL97* (Sheldrick, 1997).

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